



COPY OF PAPERS ORIGINALLY FILED

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Halimaoui, et al.

Serial No.:

09/744,877

Filed:

January 29, 2001

For:

PROCESS FOR FORMING AN OXIDE LAYER OF NON-UNIFORM THICKNESS ON THE SURFACE OF A SILICON SUBSTRATE

Examiner:

Christy L. Novacek

Group Art Unit:

2822

Attorney Docket:

5310-03000/EBM

CERTIFICATE OF MAILING 37 C.F.R. § 1.8

I hereby certify that this correspondence is being deposited with the U.S. Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, Office of Initial Patent Examination, Customer Service Center, Washington, D.C. 20231, on the date below:

3-4-M

Date

ckie L. Pitre

AMENDMENT; RESPONSE TO OFFICE ACTION MAILED DECEMBER 3, 2001

§ §

Commissioner for Patents Washington, D.C. 20231

Sir:

Amendment

Please amend the above-captioned application as follows:

APR-2 2002

In The Specification:

Please amend the specification to read as shown below. A "marked up" version of the amended paragraphs is included as an attachment to this response.